

## EAST Search History

## EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	589	(425/389).OCLS	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/11 12:07
L2	1427589	@ad> "20061119" or @pd> "20091119"	US-PGPUB; USPAT	ADJ	ON	2011/03/11 13:14
L3	2930	((425/174.4) or (425/385) or (425/389)).OCLS	US-PGPUB; USPAT	OR	OFF	2011/03/11 13:14
L4	451	L2 and L3	US-PGPUB; USPAT	ADJ	ON	2011/03/11 13:14
L5	857574	@ad> "20101026" or @pd> "20101026"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/11 13:14
L6	87	4 and 5	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/11 13:14
S1	24	("20030071016"   "20030159608"   "20030159608"   "20030189273"   "20040079730"   "20040110856"   "20040131718"   "20040131718"   "20050158419"   "20050202350"   "4054383"   "4360266"   "4844947"   "5804017"   "5947027"   "6027630"   "6190929"   "6284345"   "6334960"   "6387778"   "6387787"   "6743740"   "6949199"   "6482742"   "7144539"   "7374864"). PN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/04/27 15:34
S2	1	("20010013920").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/04/28 12:24

S3	32	((BABAQ) near2 (HEIDARI)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/04/28 14:33
S4	15	((MARQ) near2 (BECK)).INV.	US-PGPUB; USPAT	ADJ	ON	2010/04/28 14:33
S6	4351	((425/174.4) or (425/385) or (425/387.1) or (425/389) or (264/293)).CCLS.	US-PGPUB; USPAT	OR	OFF	2010/04/28 14:40
S7	2	((("6387787") or ("6334960")).PN.	US-PGPUB; USPAT	OR	OFF	2010/04/28 14:41
S8	1	("20030159608").PN.	US-PGPUB; USPAT	OR	OFF	2010/04/30 10:12
S9	4355	((425/174.4) or (425/385) or (425/387.1) or (425/389) or (264/293)).CCLS.	US-PGPUB; USPAT	OR	OFF	2010/04/30 11:08
S10	212	S9 and imprint lithography	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:08
S11	923257	@ad> "20061119" or @pd> "20091119"	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:09
S12	2721	((425/174.4) or (425/385) or (425/389)).CCLS.	US-PGPUB; USPAT	OR	OFF	2010/04/30 11:24
S13	242	S11 and S12	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:24
S14	1634	S9 not S12	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:24
S15	63	S14 and S10	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:25
S16	157	S14 and S11	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:25
S17	11528	(rubber near seal)	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:26
S18	11	polymer rubber seal	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:26
S19	7557	(polymer rubber) or (polymeric rubber)	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:27
S20	1	((polymeric rubber) seal)	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:27
S21	7012	"polymer rubber"	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:28
S22	11	"polymer rubber" seal	US-PGPUB; USPAT	ADJ	ON	2010/04/30 11:28
S23	4424	((425/174.4) or (425/385) or (425/387.1) or (425/389) or (264/293)).CCLS.	US-PGPUB; USPAT	OR	OFF	2010/07/12 12:51
S24	344	(radiation and wavelength and transparent) and S23	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:52

S25	8240	transparent near radiation	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:53
S26	63	S24 and S25	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:53
S27	92	uv imprint lithography	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:56
S28	607	(flexible near membrane) and (imprint or lithography) and (uv or ultraviolet or ultra violet or radiation)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:59
S29	19	S28 and "425".clas.	US-PGPUB; USPAT	ADJ	ON	2010/07/12 12:59
S30	13	S29 and transparent	US-PGPUB; USPAT	ADJ	ON	2010/07/12 13:01
S31	4379	uv laser and pulse	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:27
S32	660	pulses per second and laser and uv	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:27
S33	340	S32 and pulse duration	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:27
S34	125	S33 and (micro second or microsecond)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:28
S35	34	S34 and (polymer or pmma)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:29
S36	20651	xenon (lamp or laser)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:32
S37	12949	S36 and (uv or ultraviolet)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:32
S38	2543	S37 and pulse	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:32
S39	386	S38 and (cure and (polymer or pmma))	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:32
S40	0	S39 and S34	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:33
S41	89	S39 and (microsecond or micro second)	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:33
S42	175	(xenon lamp).ab.	US-PGPUB; USPAT	ADJ	ON	2010/07/12 14:34
S43	6341	((425/174.4) or (425/385) or (425/389) or (425/387.1) or (264/293)). CCLS.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/10/26 10:55

S44	618833	@ad> "20100712" or @pd> "20100712"	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/10/26 10:55
S45	118	S43 and S44	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/10/26 10:55
S46	2	("6252624").PN.	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/10 11:10
S47	2	("6252604").PN.	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/10 11:10
S48	6473	((425/174.4) or (425/385) or (425/389) or (425/387.1) or (264/293)). OCLS.	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2011/03/10 11:27
S49	470936	(pressure or pressured or pressurize or vacuum or vacuuming) near (chamber or cavity or region or bag or mold)	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 11:33
S50	805	S48 and S49	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 11:34
S51	58	S50 and substrate near (chamber or vacuum or cavity or pressure or pressurize)	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 11:34
S52	58	S50 and (substrate near (chamber or vacuum or cavity or pressure or pressurize))	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 11:35

S53	123	(pressre or vacuum) near3 (chamber or cavity or area or zone or compartment or cell or container)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:29
S54	31	S53 and ("425".das. or "264".das. or imprint or lithography or stamp or emboss or press or platen or pattern)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:30
S55	57	(pressre or vacuum) near (chamber or cavity or area or zone or compartment or cell or container)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:33
S56	539140	(pressure or vacuum or vacuum) near (chamber or cavity or area or zone or compartment or cell or container)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:33
S57	168669	S56 and ("425".das. or "264".das. or imprint or lithography or stamp or emboss or press or platen or pattern)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:34
S58	86511	S57 and pattern	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:34
S59	9892	S58 and lithography	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:34
S60	5502	S59 and (ultra violet or ultraviolet or uv)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:34
S61	75	S60 and S48	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/03/10 13:34

## **EAST Search History (Interference)**

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**3/ 11/ 2011 1:16:37 PM**

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